

	Type	L #	Hits	Search Text	DBs	Time Stamp	C o m m e n t s	E r r o r m e s s a g e s	E n t r y i n f o r m a t i o n
1	BRS	L8	204	(sac or "contact hole" ) same ( "hard mask" or SiO2 or SiN or Si3N4 or "silicon dioxide" or "silicon oxynitride" or SiON or SixOyNz or SiOxNy) same (BPSG)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/03 10:38			0
2	BRS	L15	75	8 and @pd<=19980927	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/10/03 10:40			0